35.C14241

PATENT APPLICATION 10/5/00

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re A	Application of:	)			
		:	Examiner	: Unass	igned
NOBUHIRO ITO		)			
		:	Group Ar	t Unit:	Unassigned
Application No.: Unassigned		)		· ·	
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Filed:	February 16, 2000	).	<b>V</b>	$= -\frac{\alpha}{2} D^{3/2}$	
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For:	MANUFACTURING METHOD	:	•		
	OF ELECTRON BEAM	)	•	ان میں اگر مار میں اگر	•
	APPARATUS AND SPACER,	:	February	16, 20	00
	AND ELECTRON BEAM	)	_		
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Assistant Commissioner for Patents Washington, D.C. 20231

## COMMUNICATION

Sir:

This application is being filed in the Japanese language pursuant to MPEP 608.01 and 37 CFR 1.52(d). Applicant will file an English translation of the specification and claims, along with a statement that the translation is accurate, an executed declaration, and any additional fees, at the time to be set forth by the Patent Office.

BEST AVAILABLE COPY

Applicant's undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010.

All correspondence should continue to be directed to our below listed address.

Respectfully submitted,

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